

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

**PRELIMINARY AMENDMENT ACCOMPANYING APPLICATION**

APPLICANT: Karou Koike, et al. ATTY. DOCKET NO. 09792909-5344

SERIAL NO.

DATE FILED:

INVENTION: "MASK-MAKING MEMBER AND ITS PRODUCTION METHOD,  
MASK AND ITS MAKING METHOD, EXPOSURE PROCESS, AND  
FABRICATION METHOD OF SEMICONDUCTOR DEVICE"

Assistant Commissioner of Patents  
Washington, D.C. 20231

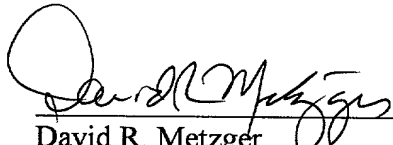
S I R:

Between the title and the heading "Background of the Invention" on page 1, insert the following:

--RELATED APPLICATION DATA

The present application claims priority to Japanese Application(s) No(s). P2001-046363 filed February 22, 2001, which application(s) is/are incorporated herein by reference to the extent permitted by law.--

Respectfully submitted,

 (Reg. No. 32,919)  
David R. Metzger  
SONNENSCHN NATH & ROSENTHAL  
P.O. Box #061080  
Wacker Drive Station  
Sears Tower  
Chicago, IL 60606-1080  
Customer #26263

Attorneys for Applicant(s)